

Electronic Supporting Information

Titanium Nitride Nanoparticles Based Electrocatalysts For Proton Exchange Membrane Fuel Cells

XRD Data of TiN

*TiN (JCPDS # 38 – 1420) Lattice Parameter a: 4.241 Å

*TiO (JCPDS # 77 – 2170) Lattice Parameter a: 4.185 Å

From XRD, Lattice parameter of TiN sample is 4.220 Å and lies between lattice parameters of TiO & TiN

$$\text{TiO (4.185 \AA)} < 4.22 \text{ \AA} < \text{TiN (4.241 \AA)}$$

which implies the existence of a (TiN_xO_{1-x}) layer on the surface of TiN.

Ref: X.Yang et al. / Chemical Physics Letters 383 (2004) 502-506.

XPS of TiN

As can be seen from the XPS graph in Figure S1, before sputtering, the TiO₂ peaks are dominating indicating the presence of oxide layer on the surface of TiN. After etching of the surface, the TiN peak appears with a simultaneous reduction of TiO₂ peak thus indicating the presence of oxygen rich layer on the surface of TiN.

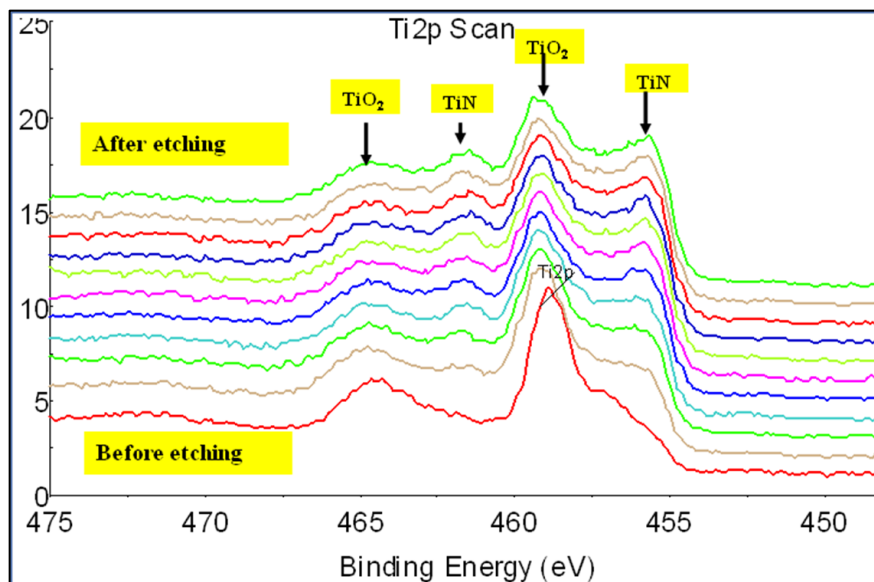


Figure S1: XPS of TiN (Ti2p scan) before and after Ar⁺ sputtering for 150s at 0.1nm/s

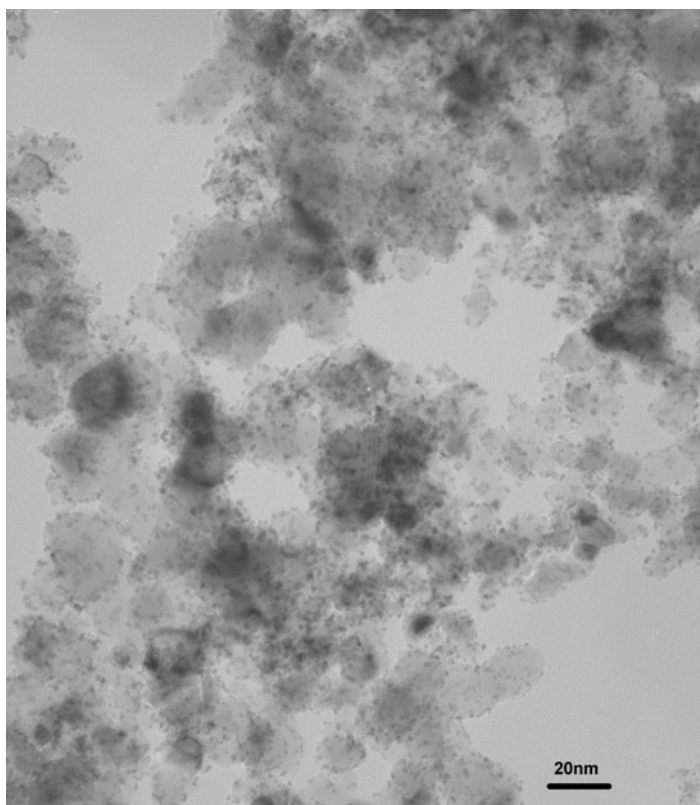


Figure S2. TEM micrograph of Pt/TiN prepared using polyol process

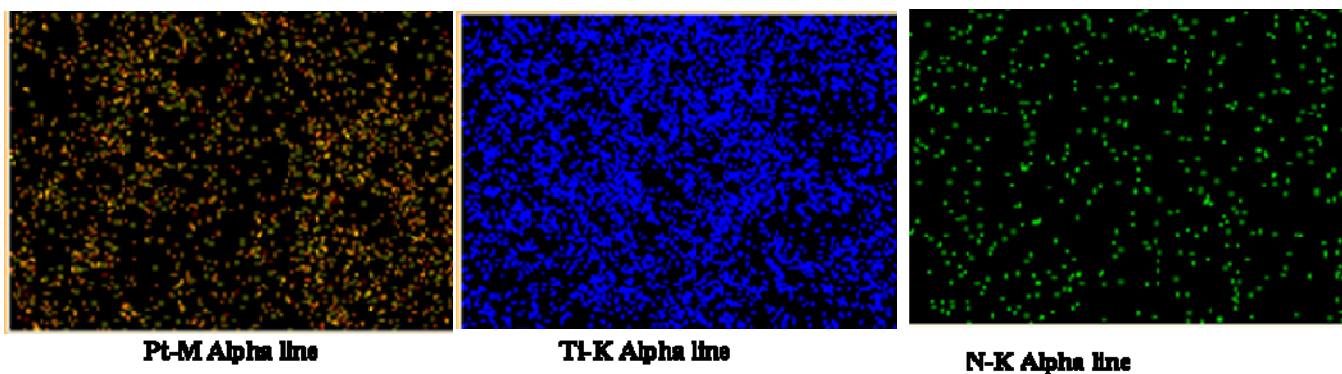


Figure S3. X-Ray Mapping of Pt/TiN shows uniform distribution of Pt and TiN

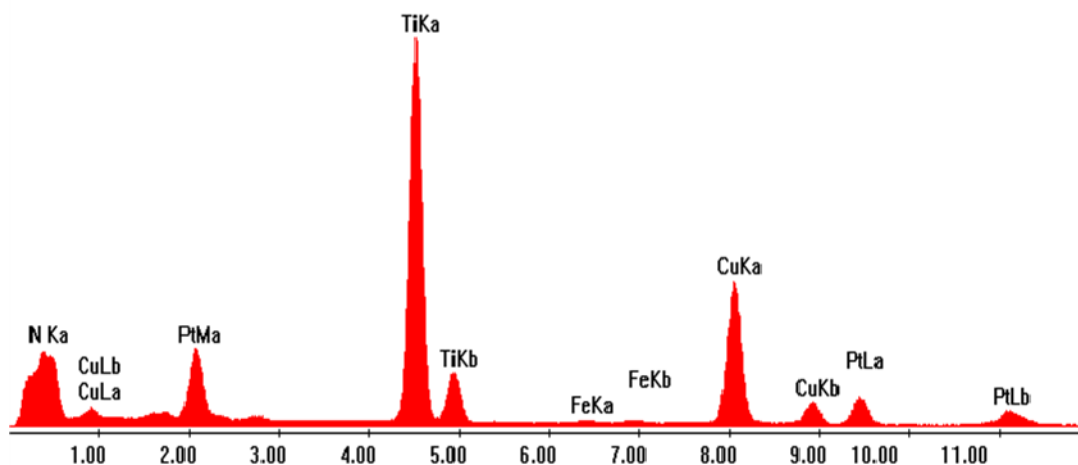


Figure S4. Energy Dispersive Spectra (EDS) High Resolution TEM based EDS of Pt/TiN on a copper grid. The peaks of Cu and Fe are from the Cu grid used while taking TEM images.